

APPLICATION  
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TITLE: CMOS ACTIVE PIXEL SENSOR TYPE IMAGING SYSTEM ON A  
CHIP

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~~CMOS ACTIVE PIXEL SENSOR TYPE IMAGING SYSTEM ON A CHIP~~

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5 Serial No. 08/188,032, filed January 28, 1994, and claims  
priority from provisional application no 60/010,678 having a  
filing date of January 26, 1996.

[illegible]

The invention described herein was made in

The present invention relates to a single chip  
15 imaging sensor.

## Background and Summary of the Invention

Imaging technology is the science of converting an image to a signal indicative thereof. Imaging systems have

broad applications in many fields, including commercial, consumer, industrial, medical, defense and scientific markets.

5 The original image sensors included an array of  
photosensitive elements in series with switching elements.  
Each photosensitive element received an image of a portion  
of the scene being imaged. That portion is called a picture  
element or pixel. The image obtaining elements produce an  
electrical signal indicative of the image plus a noise  
10 component. Various techniques have been used in the art to  
minimize the noise, to thereby produce an output signal that  
closely follows the image.

Size minimization is also important. The  
development of the solid state charge coupled device ("CCD")

in the early 1970's led to more compact image systems. CCDs use a process of repeated lateral transfer of charge in an MOS electrode-based analog shift register. Photo-generated signal electrons are read after they are shifted into.

5 appropriate positions. However, the shifting process requires high fidelity and low loss. A specialized semiconductor fabrication process was used to obtain these characteristics.

CCDs are mostly capacitive devices and hence  
10 dissipate very little power. The major power dissipation in a CCD system is from the support electronics. One reason for this problem is because of the realities of forming a CCD system.

The specialized semiconductor fabrication process alluded to above is not generally CMOS compatible. Hence, the support circuitry for such a CCD has been formed using control electronics which were not generally CMOS

5 compatible. The control electronics have dissipated an inordinate percentage of the power in such imaging devices. For example, CCD-based camcorder imaging systems typically operate for an hour on an 1800 mA-hr 6 V NiCad rechargeable battery, corresponding to 10.8 W of power consumption.

10 Approximately 8 watts of this is dissipated in the imaging system. The rest is used by the tape recording system, display, and autofocus servos.

Space-based imaging systems often have similar problems. The space based systems operate at lower pixel

rates, but with a lower degree of integration, and typically dissipate 20 watts or more.

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The CCD has many characteristics which cause it to act like a chip-sized MOS capacitor. The large capacitance  
5 of the MOS device, for example, requires large clock swings,  $\Delta V$ , of the order of 5-15 V to achieve high charge transfer efficiency. The clock drive electronics dissipation is proportional to  $C\Delta V^2 f$ , and hence becomes large. In  
addition, the need for various CCD clocking voltages (e.g. 7  
10 or more different voltage levels) leads to numerous power supplies with their attendant inefficiencies in conversion.

Signal chain electronics that perform correlated double sampling ("CDS") for noise reduction and

amplification, and especially analog to digital converters (ADC), also dissipate significant power.

The inventors also noted other inefficiencies in imaging systems. These inefficiencies included fill factor  
5 inefficiencies, fixed pattern noise, clock pick up, temporal noise and large pixel size.

Active pixel sensors, such as described in U.S. Patent no. 5,471,515, the disclosure of which is incorporated by reference herein, use special techniques to integrate  
10 both the photodetector and the readout amplifier into the pixel area or adjacent the pixel area. This allows the signal indicative of the pixel to be read out directly. These techniques have enabled use of a logic family whose fabrication processes are compatible with CMOS. This has

enabled the controlling circuitry to be made from CMOS or some other low power-dissipating logic family.

The inventors of the present invention have recognized techniques and special efficiencies that are  
5 obtained by specialized support electronics that are integrated onto the same substrate as the photosensitive element. Aspects of the present invention include integration, timing, control electronics, signal chain . electronics, A/D conversion, and other important control  
10 systems integrated on the same substrate as the photosensitive element.

It is hence an object of the present invention to provide for the integration of an entire imaging system on a chip.



Brief Description of the Drawings

Figure 1 shows a basic block diagram of a CMOS active pixel circuit;

Figure 2 shows a graph of typical APS quantum efficiency;

Figure 3 shows the block diagram of the overall chip including drivers and controlling structures;

Figures 4A and 4B show the timing diagrams for photogate operation and photodiode operation, respectively;

Figure 5 shows a schematic of the active pixel sensor unit cell and readout circuitry;

Figure 6 shows a timing diagram for setup and readout;

Figure 7 shows a drawing of an actual layout of the pixel and control circuitry;

Figure 8 shows a block diagram of a CMOS APS chip; and

5 Figure 9 shows an exemplary pixel layout.

Description of the Preferred Embodiments

An active pixel sensor is herewith described with reference to Figures 1-4.

10 A block diagram of a CMOS active pixel circuit is shown in Fig. 1. The device has a pixel circuit 150, and a column circuit 155.

Incident photons pass through the photogate ("PG") 100 in the pixel circuit 150 and generate electrons which

are integrated and stored under PG 100. A number of the pixel circuits are arranged in each row of the circuit. One of the rows is selected for readout by enabling the row selection transistor 102 ("RS").

5 In the preferred embodiment, the floating diffusion output node 104 ("FD") is first reset by pulsing reset transistor ("RST") 106. The resultant voltage on FD 104 is read out from the pixel circuitry onto the column bus 112 using the source follower 110 within the pixel. The voltage  
10 on the column bus 112 is sampled onto a first holding capacitor 114 by pulsing transistor SHR 116. This initial charge is used as the baseline.

The signal charge is then transferred to FD 104 by pulsing PG 100 low. The voltage on FD 104 drops in

proportion to the number of photoelectrons and the  
capacitance of FD. The new voltage on the column bus 112 is  
sampled onto a second capacitor 118 by pulsing SHR 120. The  
difference between the voltages on first capacitor 114 and  
5 second capacitor 118 is therefore indicative of the number  
of photoelectrons that were allowed to enter the floating  
diffusion.

The capacitors 114, 118 are preferably 1-4 pf  
capacitors.

10 All pixels on a selected row are processed  
simultaneously and sampled onto capacitor at the bottom of  
their respective columns. The column-parallel sampling  
process typically takes 1-10  $\mu$ sec, and preferably occurs

during the so-called horizontal blanking interval of a video image.

Each column is successively selected for read-out by turning on column selection p-channel transistors ("CS")

5 130. The p-channel source-followers 122, 124 in the column respectively drive the signal (SIG) and horizontal reset (RST) bus lines. These lines are loaded by p-channel load transistors which can be sent directly to a pad for off-chip drive, or can be buffered.

10 Noise in the sensor is preferably suppressed by the above-described correlated double sampling ("CDS") between the pixel output just after reset, before and after signal charge transfer to FD as described above. The CDS suppresses kTC noise from pixel reset, suppresses 1/f noise

from the in-pixel source follower, and suppresses fixed pattern noise (FPN) originating from pixel-to-pixel variation in source follower threshold voltage.

The inventors found, however, that kTC noise may be  
5 reintroduced by sampling the signal onto the capacitors 114, 118 at the bottom of the column. Typical output noise measured in CMOS APS arrays is of the order of  $140\text{-}170 \mu\text{V/e-}$ , corresponding to noise of the order of 13-25 electrons r.m.s. This is similar to noise obtained in most commercial  
10 CCDs, through scientific CCDs have been reported with read noise in the 3-5 electrons rms.

Typical biasing for each column's source-follower is  $10 \mu\text{A}$ . This permits charging of the sampling capacitors in

the allotted time. The source-followers can then be turned off by cutting the voltage on each load transistor.

The sampling average power dissipation  $P_s$  corresponds to :

5 
$$P_s = n I V d$$

where n is number of columns, I is the load transistor bias, V is the supply voltage, and d is the duty cycle. Using  $n=512$ ,  $I=\mu A$ ,  $V=5V$  and  $d=10\%$ , a value for  $P_s$  of 2.5mW is obtained.

10 A load current of 1 mA or more is needed to drive the horizontal bus lines at the video scan rate. The power dissipated is typically 5 mW.

Quantum efficiency measured in this CMOS APS array is similar to that for interline CCDs. A typical response curve is shown in Fig. 2. The inventors noticed from this that the quantum efficiency reflects significant

5   responsivity in the "dead" part of the pixel; the part containing the readout circuitry rather than the photogate collector. The responsiveness was measured by intra-pixel laser spot scanning.

10   The inventors postulate the following reason. The transistor gate and channel absorb photons with short absorption lengths (i.e. blue/green). However, longer wavelength photons penetrate through these regions. The subsequently-generated carriers diffuse laterally and are subsequently collected by the photogate.



Thus, despite a fill factor of 25%-30%, the CMOS APS achieves quantum efficiencies that peak between 30%-35% in the red and near infrared. Microlenses are preferably added to refract photoelectrons from the dead part to a live part  
5 and hence improve quantum efficiency.

An important feature of the system described herein is the integration of on-chip timing and control circuits within the same substrate that houses the pixel array and the signal chain electronics. A block diagram of the chip  
10 architecture is shown in Fig. 3.

The analog outputs VS\_out (signal) and VR\_out (reset) are as described above. The digital outputs include FRAME and READ. Most of the inputs to the chip are asynchronous digital signals, as described herein.

The chip includes a pixel array 300, which is driven by on-chip electronics. Timing and control circuit 302 drives row electronics 310, and column electronics 320.

The control circuits can command read-out of any  
5 area of interest within the array. Row decoder 312 controls row drivers 314 which can select a certain row for readout. A specific row is selected by entry of a row value 316 which is output from timing and control 302. Row value 316 is stored in latch 318 which drives counter 319. Counter 319  
10 can allow selection of subsequent rows that follow the current row. Similarly, columns can be selected and accessed by latches 322, counter 324, decoder 326 and column signal conditioning 328.

Each of the decoder counters can be preset to start and stop at any value that has been loaded into the chip via the 8-bit data bus 330. Therefore, as described above, selection of a row commands pixels in that row to be

5 transferred to the appropriate row decoding elements, e.g., capacitors. Preferably there is one capacitor associated with each column. This provides for the sequential readout of rows using the column. The capacitors are preferably included within the column signal conditioner 328. Column  
10 decoders 326 also allow selection of only a certain column to be read. There are two parts of each column selection: where to start reading, and where to stop reading.

Preferably the operation is carried out using counters and registers. A binary up-counter within the decoder 326 is

preset to the start value. A preset number of rows is used by loading the 2's compliment. The up counter then counts up until an overflow.

An alternate loading command is provided using the  
5 DEFAULT LOAD input line 332. Activation of this line forces all counters to a readout window of 128 x 128.

A programmable integration time is set by adjusting the delay between the end of one frame and the beginning of the next. This parameter is set by loading a 32-bit latch  
10 via the input data bus 330. A 32-bit counter operates from one-fourth the clock input frequency and is preset at each frame from the latch. The counter can hence provide vary large integration delays. The input clock can be any frequency up to about 10 MHZ. The pixel readout rate is

5 tied to one-fourth the clock rate. Thus, frame rate is determined by the clock frequency, the window settings, and the delay integration time. The integration time is therefore equal to the delay time and the readout time for a 2.5 MHZ clock. The maximum delay time is  $2^{32} / 2.5 \text{ MHZ}$ , or around 28 minutes. These values therefore easily allow obtaining a 30 Hz frame.

10 The timing and control circuit controls the phase generation to generate the sequences for accessing the rows. The sequences must occur in a specified order. However, different sequences are used for different modes of operation. The system is selectable between the photodiode mode of operation and the photogate mode of operation. The timing diagrams for the two gates are respectively shown in

Figures 4a and 4b. Figure 4a shows an operation to operate in the photogate mode and Figure 4b shows operating in the photodiode mode. These different timing diagrams show that different column operations are possible. Conceptually this is done as follows. Column fixed pattern noise is based on differences in source follower thresholds between the different transistors. For example, if the base bias on a transistor is  $V_1$ , the output is  $V_1$  plus the threshold.

The column signal conditioning circuitry contains a double-delta sampling fixed pattern noise ("FPN") suppression stage that reduces FPN to below 0.2% sat with a random distribution. Since the APS is formed of a logic family that is compatible with CMOS, e.g., NMOS, the circuitry can be formed of CMOS. This allows power

dissipation in the timing and control digital circuitry to be minimized and to scale with clock rate.

An active pixel sensor includes both a photodetector and the readout amplifier integrated within the same  
5 substrate as the light collecting device, e.g., the photodiode. The readout amplifier is preferably within and/or associated with a pixel.

A first embodiment of the present invention is a 128 x 128 CMOS photodiode type active pixel sensor that includes  
10 on chip timing, control and signal train electronics. A more detailed drawing of the chip is shown in Figure 5. Asynchronous digital signals are converted by this chip to VS and VR analog outputs which are used to run the chip.

Pixel portion 500 includes a photodiode 502 which stores incident photons under photogate 504. The photons are integrated as electrons within the photogate well. The output is buffered by follower 508.

5           The rows are arranged into an array. A particular row is selected by the row transistor 514. This allows the information from within the selected pixel 500 to be passed to the column decoder circuitry. Reset transistor 530 is connected to a sink 532. Reset transistor is biased to a  
10 low potential level to allow all charge to bleed to sink 532, and hence hold the stored charge in reset. The system is removed from reset by biasing the gate to a level as shown. This level is less than a highest possible potential to thereby allow charge which accumulates above that level



to pass to sink 532. Hence, the charge cannot overflow in an undesired way. This suppresses the blooming effect.

The depicted photogate system is driven according to the readout sequence shown in Figure 6. A row is selected  
5 by activating row selecting transistor 514. The cycle begins by sampling the signal present on each column pixel in that row. Sampling is initiated by biasing transistor 526 to place the signal from each column pixel in the row onto the holding capacitor 510. \*

10 After the current pixel value has been transferred to the capacitor 510, the pixel in the row is reset by biasing reset transistor to a low level, to photodiode 502 to the preset voltage sink 532.

Correlated double sampling is effected by sampling the reset value, as a reset level, onto the holding capacitor 512. This is done by activating the reset transistor 516.

5           The voltage value of the reset branch of the column circuit is given by

$$V_{col\_R} = \beta \{ \alpha [V_{pdr} - V_{tpix}] - V_{tcolr} \}$$

Where  $\alpha$  is the gain of the pixel source follower 508,  $\beta$  is the gain of the column source follower 526, and  $V_{pdr}$  is the  
10 voltage on the photodiode after reset,  $V_{tpix}$  is the threshold voltage of the pixel source follower and channel transistor, and  $V_{tcolr}$  is the threshold voltage of the column source follower p-channel transistor.

Using similar reasoning, the output voltage of the signal branch of the column circuit is

$$V_{col\_S} = \beta \{ \alpha [V_{pds} - V_{tpix}] - V_{tcols} \}$$

where  $V_{pds}$  is the voltage on the photodiode with the signal charge present and  $V_{tcols}$  is the threshold voltage of the column source-follower p-channel transistor.

The inventors have found experimentally that the peak-to-peak variation  $V_{tcolr} - V_{tcols}$  is typically between 10 and 20 millivolts. This, however, is a source of column to column fixed pattern noise. The inventors herein suggest a double delta sampling technique to eliminate this column to column noise. The present approach represents an improved version of the previously-described double delta sampling circuitry. The operation proceeds as follows. A column is

first selected. After a settling time equivalent to half of  
the column selection period, a special double delta sampling  
technique is performed to remove the column fixed pattern  
noise. Therefore, the varying thresholds on the different  
5 transistors cause varying outputs. According to this  
aspect, the threshold outputs of these transistors are  
equalized using a capacitor to equalize the charge. The  
capacitor is applied with the charge before and after the  
voltage change. Therefore, the output of the capacitor  
10 represents the difference between before and after, and the  
fixed pattern noise component drops out of the equation.

This system uses a DDS switch 520 and first and  
second column select switches 522, 524 to short across the  
respective capacitors. All three switches are turned on to

short across the two sample and hold capacitors 510. This clamp operation is shown in line 8 of Figure 6.

Prior to the DDS operation, the reset and signal column components,  $V_{col\_R}$  and  $V_{col\_S}$  include their signal values plus a source follower voltage threshold component from the appropriate source follower. The object of the special following circuit of the present invention is to remove that source follower threshold component.. The operation proceeds as follows. Prior to the beginning of some operation, the capacitors are precharged through clamp transistors to a clamp voltage  $V_{c1}$ . This is maintained by turning on clamp transistors 550 and 552 to connect the appropriate capacitors to the voltage  $V_{c1}$ . The clamp operation is shown on line 8 of Figure 6. Immediately after

the clamp is released, the DDS transistors 520, 522 and 524 are turned on. This has the effect of shorting across the capacitors 510 and 512. When the transistors are shorted, the voltage that is applied to the output drivers 554, 556

5 includes only the voltage threshold component. The differential amplification of the voltage render the output voltage free of the voltage threshold component.

Mathematically, prior to clamp being deactivated, the output signals are:

10 
$$VR\_OUT = \gamma(V_{cl} - V_{tr})$$

and 
$$VS\_OUT = \gamma(V_{cl} - V_{ts})$$

where  $\gamma$  is the gain of the third stage source-follower,  $V_{cl}$  is the clamp voltage, and  $V_{tr}$  and  $V_{ts}$  are the threshold voltages of the third stage source-follower n-channel

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transistors, reset and signal branch respectively.

Deactivation of the clamp circuit and simultaneous activation of the DDS switch causes several changes. The voltages in the two column branch sampling circuits equalize

5 becoming:

$$V_{cs} = V_{cr} = \alpha[V_{pdr} - V_{tpix} + V_{pds} - V_{tpix}]/2$$

This in turn causes a change in  $V_{col\_S}$  and  $V_{col\_R}$  to:

$$V_{col\_R}' = \beta\{\alpha[V_{pdr} - V_{tpix} + V_{pds} - V_{tpix}]/2 - V_{tcolr}\}$$

$$\text{and } V_{col\_S}' = \beta\{\alpha[V_{pdr} - V_{tpix} + V_{pds} - V_{tpix}]/2 - V_{tcols}\}$$

10 Consequently, the voltage outputs change to:

$$VR\_OUT = \gamma(V_{c1} - V_{col\_R}' - V_{col\_R} - V_{tr})$$

$$\text{and } VS\_OUT = \gamma(V_{c1} - V_{col\_S}' - V_{col\_S} - V_{ts})$$

We note

$$V_{col\_S'} - V_{col\_S} = \beta \{ \alpha [V_{pds} - V_{pdr}] / 2 \}$$

and  $V_{col\_R'} - V_{col\_R} = \beta \{ \alpha [V_{pdr} - V_{pds}] / 2 \}$

When the outputs are differentially amplified off-chip, the common clamp voltage  $V_{cl}$  is removed, leaving only the  
5 difference between signal and reset. The net differential output voltage is given by:

$$V_{R\_OUT} - V_{S\_OUT} = \alpha \beta \gamma (V_{pdr} - V_{pds} = V_{const})$$

Figure 7 shows the layout of the pixel for 128 x 128 array size device. This system formed a 19.2 micron pixel  
10 size using 1.2  $\mu m$  n-well CMOS. The maximum clock rate is 10 MHZ, the maximum pixel rate is 2.5 MHZ and maximum integration delay is  $1.6 \times 10^9$  clock periods.



A second embodiment uses similar design techniques to produce a 256 x 256 array size. This embodiment also uses a pixel with a photogate imaging element along with four transistors to perform the functions of readout, selection, and reset. Readout is preferably achieved using a column parallel architecture which is multiplexed one row at a time and then one column at a time through an on-chip amplifier/buffer. An important part of this embodiment, like the first embodiment, is the use of a chip common logic elements to control row and address decoders and delay counters.

This embodiment allows use in three modes of operation: Photogate mode, photodiode mode and differencing mode. The photogate mode is the standard mode for this

chip. The photodiode mode alters the readout timing to be similar to that for photodiode operation. The differencing mode alters the readout timing in such a way that the value of each pixel output is the difference between the current  
5 frame and the previous frame. The chip inputs that are required are a single +5 V power supply, start command, and parallel data load commands for defining integration time and windowing parameters. The output has two differential analog channels.

10 The second embodiment uses the block diagram of the chip architecture shown in figure 8. The analog outputs of VS\_OUT (signal) and VR\_OUT (reset), and digital outputs of FRAME and READ. The inputs to the chip are asynchronous digital signals. The chip includes addressing circuitry

A programmable integration time is set by adjusting the delay between the end of one frame and the beginning of the next. This parameter is set by loading a 32-bit latch via the input data bus. A 32-bit counter operates from one-fourth the clock input frequency and is preset at each frame from the latch. This counter allows forming very large integration delays. The input clock can be any frequency up

to about 10 MHZ. The pixel readout rate is tied to one  
fourth the clock rate. Thus, frame rate is determined by  
the clock frequency, the window settings, and the delay  
integration time. A 30 HZ frame rate can be achieved  
5 without difficulty.

The chip is idle when the RUN command is  
deactivated. This is the recommended time for setting the  
operating parameters. However, these parameters can be set  
at any time because of the asynchronous nature of operation.  
10 When RUN is activated, the chip begins continuous readout of  
frames based on the parameters loaded in the control  
registers. When RUN is deactivated, the frame in progress  
runs to completion and then stops.

The 256x256 CMOS APS uses a system having a similar block diagram to those described previously. The pixel unit cell has a photogate (PG), a source-follower input transistor, a row selection transistor and a reset

5 transistor. A load transistor VLN and two output branches to store the reset and signal levels are located at the bottom of each column of pixels. Each branch has a sample and hold capacitor (CS or CR) with a sampling switch (SHS or SHR) and a source-follower with a column-selection switch  
10 (COL). The reset and signal levels are read out differentially, allowing correlated double sampling to suppress 1/f noise and fixed pattern noise (not kTC noise) from the pixel.

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A double delta sampling (DDS) circuit shorts the sampled signals during the readout cycle reducing column fixed pattern noise. These readout circuits are common to an entire column of pixels. The load transistors of the

5 second set of source followers (VLP) and the subsequent clamp circuits and output source followers are common to the entire array. After a row has been selected, each pixel is reset (RESET) and the reset value is sampled (SHR) onto the holding capacitor CR. Next, the charge under each photogate

10 in the row is transferred to the floating diffusion (FD). This is followed by sampling this level (SHS) onto holding capacitor CS. These signals are then placed on the output data bus by the column select circuitry. In the Photodiode mode this process, is reversed; first the charge under the

photogate is read out and then the reset level is sampled. This non-correlated double sampling mode would be primarily used with a photodiode, i.e., non active pixel sensor, pixel.

5           In the differencing mode, the capacitors CS and CR are used to store the signal from the previous frame and the current frame. This is achieved by altering the timing in the following way: Rather than starting with a reset operation, the signal on the floating diffusion is read out  
10 to one of the sample and hold capacitors. This represents the previous pixel value. The reset is then performed followed by a normal read operation. This value is then stored on the other sample and hold capacitor. The

difference between these two signals is now the frame to frame difference.

A simplified expression for the output of the reset branch of the column circuit is given by:

5 
$$V_{col\_R} \approx \beta \{ \alpha [V_r - V_{tpix}] - V_{tcolr} \}$$

where  $\alpha$  is the gain of the pixel source-follower,  $\beta$  is the gain of the column source-follower,  $V_r$  is the voltage on the floating diffusion after reset,  $V_{tpix}$  is the threshold voltage of the pixel source-follower n-channel transistor, and  $V_{tcolr}$  is the threshold voltage of the column source-follower p-channel transistor. Similarly, the output

10



voltage of the signal branch of the column circuit is given by:

$$V_{col\_S} = \beta \{ \alpha [V_S - V_{tpix}] - V_{tcols} \}$$

where  $V_S$  is the voltage on the floating diffusion with the  
5 signal charge present and  $V_{tcols}$  is the threshold voltage of  
the column source-follower p-channel transistor.

Experimentally, the peak to peak variation in  $V_{tcolr} - V_{tcols}$  is  
typically 10-20 mV. It is desirable to remove this source  
of column-to-column fixed pattern noise FPN. JPL has  
10 previously developed a double delta sampling (DDS) technique  
to eliminate the column-to-column FPN. This approach  
represented an improved version of the DDS circuitry.

Sequential readout of each column is as follows.

First a column is selected. After a settling time  
equivalent to one-half the column selection period, the DDS  
is performed to remove column fixed pattern noise. In this  
5 operation, a DDS switch and two column selection switches on  
either side are used to short the two sample and hold  
capacitors CS and CR. Prior to the DDS operation the reset  
and signal outputs (Vcol\_R and VCOL\_S) contain their  
respective signal values plus a source follower voltage  
10 threshold component. The DDS switch is activated  
immediately after CLAMP is turned off. The result is a  
difference voltage coupled to the output drivers (VR\_OUT and  
VS\_OUT) that is free of the voltage threshold component.

This chip uses a similar pixel cell to that shown in Figure 5. Figure 9 shows the layout of the pixel cell. PG and RESET are routed horizontally in polysilicon while the pixel output is routed vertically in metal1. Metal2 was  
5 routed within the pixel for row selection. Metal2 was also used as a light shield and covers most of the active area outside of the pixel array. The designed fill factor of the pixel is approximately 21%.

According to another feature, a logo can be formed  
10 on the acquired image by using a light blocking metal light shield. The light shield is formed to cover certain pixels in the shape of the logo to be applied. This blocks out those underlying pixels in the array, thereby forming a logo in the shape of the blocked pixels.

10 Dark current was measured at less than 500 pA/cm<sup>2</sup>.

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similar to the value found in CCDs and consistent with the well-controlled gain of a source-follower buffer.

The quantum efficiency of the detector was measured using a CVI 1/4 m monochromator and a tungsten/halogen light source, calibrated using a photodiode traceable to NIST standards.

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